



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#32/G  
10/23/31  
Sunder

Application Serial No. .... 09/233,377  
Confirmation No. .... 7580  
Filing Date ..... January 18, 1999  
Inventor..... Gurtej S. Sandhu et al.  
Assignee..... Micron Technology, Inc.  
Group Art Unit..... 2813  
Examiner ..... Pham, Thanhha S.  
Attorney's Docket No. .... MI22-1114  
Customer No. .... 021567  
Title: Method of Forming a Refractory Metal Silicide

**RESPONSE TO JULY 9, 2003 OFFICE ACTION**

To: Mail Stop Non-Fee Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

RECEIVED  
OCT 16 2003  
TC 2800 MAIL ROOM

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**AMENDMENTS**

In response to the Office Action of July 9, 2003, please amend the above-identified application as follows.